Docket No. 00862.022239

In re Application of:

SHIGEYUKI UZAWA, ET AL.

Application No.: 09/864,309

Filed: May 25, 2001

For: EXPOSURE APPARATUS, COATING/

DEVELOPING SYSTEM, DEVICE

MANUFACTURING SYSTEM, DEVICE

MANUFACTURING METHOD,

SEMICONDUCTOR MANUFACTURING FACTORY, AND EXPOSURE APPARATUS

MAINTENANCE METHOD

November 10, 2004

Examiner: Ryan A. Jarrett

Group Art Unit: 2125

Mail Stop Amendment

Commissioner For Patents P.O. Box 1450 Alexandria, Virginia 22313-1450

Sir:

Transmitted herewith is an Amendment in the above-identified application.

X No additional fee is required.

The fee has been calculated as shown below:

			CLAIMS AS AMEND	DED		
	(2) CLAIMS REMAINING AFTER AMENDMENT		(4) HIGHEST NO. PREVIOUSLY PAID FOR	(5) PRESENT EXTRA	RATE	ADDITIONAL FEE
TOTAL CLAIMS	14	MINUS	47	= 0	x \$9 \$18	0.00
INDEP. CLAIMS	1	MINUS	9	= 0	x \$43 \$88	0.00
Fee for Mult	0.00					
TOTAL ADDITIONAL FEE FOR THIS AMENDMENT						0.00

	°Verified Statement claiming small entity status is enclosed, if not filed previously.
	A check in the amount of \$ is enclosed.
	Charge \$ to Deposit Account No. 06-1205. A duplicate copy of this sheet is enclosed.
X	Any prior general authorization to charge an issue fee under 37 C.F.R. 1.18 to Deposit Account No. 06-1205 is hereby revoked. The Commissioner is hereby authorized to charge any additional fees under 37 C.F.R. 1.16 and 1.17 which may be required during the entire pendency of this application, or to credit any overpayment, to Deposit Account No. 06-1205. A duplicate copy of this paper is enclosed.
	A check in the amount of \$ to cover the fee for a month extension is enclosed.
	A check in the amount of \$ to cover the Information Disclosure Statement fee is enclosed.
X	Applicants' attorney, Steven E. Warner, may be reached in our Washington, D.C. office by telephone at (202) 530-1010. All correspondence should continue to be directed to our address given below.

Respectfully submitted,

Jaøk/S. Cubert

Attorney for Applicants Registration No. 24,245

FITZPATRICK, CELLA, HARPER & SCINTO 30 Rockefeller Plaza
New York, New York 10112-3800
Facsimile: (212) 218-2200
SEWJSC/dc

DC\_MAIN 184065v1

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:	)	
	:	Examiner: Ryan A. Jarrett
SHIGEYUKI UZAWA, ET AL.	)	
	:	Group Art Unit: 2125
Application No.: 09/864,309	)	
	:	
Filed: May 25, 2001	)	
	:	
For: EXPOSURE APPARATUS,	)	
COATING/DEVELOPING SYSTEM	:	
DEVICE MANUFACTURING SYSTEM,	, )	
DEVICE MANUFACTURING METHOD	), :	
SEMICONDUCTOR MANUFACTURING	G)	
FACTORY, AND EXPOSURE	:	
APPARATUS MAINTENANCE METHO	)D)	November 10, 2004

Mail Stop Amendment COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450

## **AMENDMENT**

Sir:

In response to the Office Action dated August 10, 2004, please amend the above identified application as follows: